Model 2244i Specifications

Automatic Functions

Alignment options Site by Site Alignment: Enhanced Global Alignment Auto Focus: Focus Gauge: Auto wafer level: Autoloader: Reticle loader

Throughput Specifications

Reticle Load and Align: Field Change: 125mm: EGA 150mm: EGA 200mm: EGA

System specifications

Wafer Sizes: XY Stage: Computer: Printer:

Lens Specifications

Projection Ratio: Exposure Spectrum: Alignment Spectrum: Numerical Aperture: Resolution Depth of Focus: Field Size

Illumination Specifications

Automatic Exposure Control: Lamp Type: Mercury Vapor Control: Exposure Uniformity Irradiance

Reticle Specifications

Size: Pellicle Protection: KLA/NJS Inspectable: Substrate: Alignment Mark: Size: Design Flexibility: Generation Technique: Fields per reticle:

Space Requirement

Footprint: Dimensions: Service Clearance: Weight: Environmental Chamber

Stepper Environmental Req.

Ambient Temperature Control: Humidity Air quality:

Electrical Requirements

Electrical: Circuit breakers:

Pneumatic Requirements

Nitrogen or Compressed Air: Vacuum: Exhaust: Machine Vision or Darkfield alignment 0.12um, 3 sigma 0.12um, 3 sigma Continuous site by site, or global Automatic compensation for environmental fluctuations, image tilt Site by Site, electronic Robotic pick-and-place, no edge contact Robotic pick-and-place, interfaces directly

Less than 5 minutes 7 seconds 115 Wafers per hour 105 Wafers per hour 80 Wafers per hour

2", 3", 4", 5", 6", 8" Monolithic structure, linear motor drive, Active air isolation vibration control VME Bus controller; 68030 based CPU; color graphics monitor with 3.5" floppy and hard disk 80 column printer, with clean room paper

1:1 Broadband exposure, 355nm-375nm 500nm-650nm .32 Numerical Aperture 0.75um standard 1.0 um @ 0.75 um lines and spaces, 2.0ums @ 0.8um lines and spaces Max area rectangle = 44 mm x 22 mm Longest rectangle = 44 mm x 22 mm Largest square, 26.7 mm x 26.7 mm

Integrated dose monitored for exposure repeatability 750 watt mercury arc, pulsed to 1000 watts during exposure Built in +/- 2.0% > 700 mw/cm²

6" x 6" x 0.25" Chrome Side Yes Quartz or low expansion Scribe Area 200um square standard, optional cross mask size allows reduction of mark to 70um minimum Vertical or Horizontal alignment marks optional, Machine Vision E-Beam or optical step and repeat 2 fields standard, up to 7 fields total (requires optional hardware)

28 feet square ($2.5m^2$) 56.2" width x 50.4" depth x 73" height (143cm x 127.5cm x 185cm) Allow 24" on all sides, and in back Less than 5000 lbs (1.814 kilos) supported at four corners of base 68" W x 100" D x 88.5" H (172cm x 254cm x 225cm)

70 degrees , +/- 2 degrees Fahrenheit 20% to 50% noncondensing Class 100 per Federal Standard 209B

220 volts, 50/60 Hz, 15 Amps, Inrush current, 350 Amps for 5 milliseconds Separate 20 Amp circuit should be installed for each Model 2244i Each breaker should have separate ground wire returned to circuit breaker panel The circuit breaker panel should have it's ground bonded at the main transformer ground for building

reason or Compressed Air:

Minimum 100 psi, 2 CFM max, Dry to -40 degrees F dew point, filtered to 0.2 microns Two lines, each supplying 20 inches Hg at 1 SCFM average under full load, 2 SCFM max 15-20 CFM at 0.3 inch water (direct to house exhaust)

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